



**THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of: **Miwa KOZAWA et al.**

Group Art Unit: 1756

Application Number: 10/720,097

Examiner: **Daborah Chacko Davis**

Filed: **November 25, 2003**

Confirmation Number: 4454

For: **PROCESS FOR FORMING RESIST PATTERN, SEMICONDUCTOR  
DEVICE AND FABRICATION THEREOF**

Attorney Docket Number: **032132**

Customer Number: **38834**

**PETITION FOR EXTENSION OF TIME**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

May 11, 2007

Sir:

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated January 11, 2007 for one month from April 11, 2007 to May 11, 2007.

Attached please find a check in the amount of \$120.00 for the cost of the extension. If any additional fees are due in connection with this paper, please charge Deposit Account No. 50-2866.

Respectfully submitted,

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